

PHI Versaprobe II XPS

at Indiana University Bloomington

Nanoscience Characterization Facility



Enhance your research capabilities with the PHI Versaprobe II X-ray Photoelectron Spectrometer

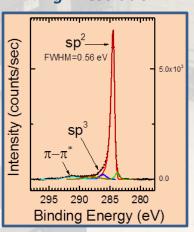
Multi-Technique Scanning XPS Microprobe

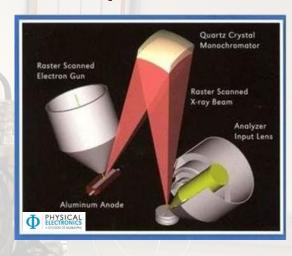
- High sensitivity micro-area chemical state analysis
- High performance sputter depth profiling
- Equipped with Ultraviolet Photoelectron Spectroscopy
- Temperature stage capabilities
- High productivity and ease-of-use

Applications

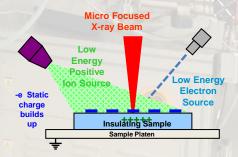
- Organic and inorganic chemistry and advanced materials research
- Surface chemistry, corrosion, catalysis, and adhesion
- Thin film characterization
- **Medical device characterization**
- Tribology, material and lubricant transfer characterization
- Magnetic storage media and complex multilayer structures
- Semiconductor and photovoltaic processes

HOPG C 1s **High Resolution**

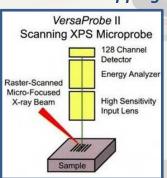


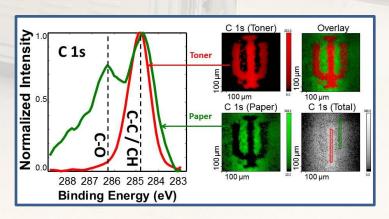


Dual Beam Charge Neutralization



Elemental Chemical Mapping





Contact Yaroslav Losovyj (ylozovyy@indiana.edu) to discuss your XPS needs http://nano.indiana.edu/XPS.html